

**PATENT APPLICATION**

Atty. Docket No.: 2522-033 Serial No. not yet assigned  
Applicant: Eung-Joon LEE, In-Sun PARK and Ji-Soon PARK  
Filing Date: July 29, 2003 Group: not yet assigned  
For: METHOD FOR FORMING SILICIDE FILM OF A SEMICONDUCTOR DEVICE

**INFORMATION DISCLOSURE CITATION  
FORM PTO-1449 (Modified)**

**U.S. PATENT DOCUMENTS**

<u>Exam Init</u>	<u>Ref</u>	<u>Document Number</u>	<u>Issue Date</u>	<u>Name</u>	<u>Class</u>	<u>Sub Class</u>
_____	_____	6,303,503B1	10/16/2001	Kamal et al.		

**FOREIGN PATENT DOCUMENTS**

<u>Exam Init</u>	<u>Ref</u>	<u>Document Number</u>	<u>Publication Date</u>	<u>Country</u>	<u>Name</u>
_____	_____				

**OTHER DOCUMENTS**

<u>Exam Init</u>	<u>Ref</u>	<u>Author, Title, Date, Pertinent Pages, Etc.)</u>

Examiner: \_\_\_\_\_

Date Considered: \_\_\_\_\_